## WHAT IS CLAIMED IS:

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- A method of cleaning a substrate for removing dirt on the substrate, comprising: irradiating a substrate surface with ultraviolet rays including
  wavelengths of 184.9 nm and 253.7 nm in an oxygen-containing atmosphere, and then subjecting the substrate to wet cleaning with pure water.
- A method according to claim 1, wherein said
  oxygen-containing atmosphere comprises atmospheric
  air.
  - 3. A method according to Claim 1, wherein said ultraviolet rays are generated from a discharge lamp.
  - 4. A method according to Claim 1, wherein said ultraviolet rays are generated from an excimer laser.
- 5. A method according to Claim 1, wherein said ultraviolet rays are generated from a plurality of sources.
- A method according to Claim 5, wherein at least one of the sources issues a wavelength selected
  from 184.9 nm and 253.7 nm.
  - 7. A method according to Claim 1, wherein at

least one of the wavelengths of 184.9 nm and 253.7 nm is a peak wavelength.

- 8. A method according to Claim 1, wherein the substrate is irradiated with ultraviolet rays at an intensity of at least  $0.2 \text{ J/cm}^2$ .
- A method according to Claim 1, wherein the substrate is subjected to the wet cleaning with pure
  water within 30 min. after the irradiation with ultraviolet rays.
  - 10. A method according to Claim 1, wherein said substrate comprises a glass substrate.

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- 11. A method according to Claim 1, wherein the substrate is subjected to the wet cleaning when the substrate surface shows a contact angle with water of at most 10 degrees after the irradiation with ultraviolet rays.
- 12. A method according to Claim 1, wherein the substrate comprises a substrate for a liquid crystal device.

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13. A method according to Claim 1, wherein the substrate comprises a glass substrate provided with a

transparent electrode.

14. A method according to Claim 13, wherein said transparent electrode comprises indium tin oxide.

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- 15. A method according to Claim 1, wherein the substrate after the wet cleaning is further irradiated with ultraviolet rays.
- 16. A method according to Claim 15, wherein the ultraviolet rays include wavelengths at 184.9 nm and 253.7 nm.

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